

09/695028

Class	Subclass
216	2

PATENT NUMBER

U.S. UTILITY Patent Application

SCANNED	Q.I.P.E.	PATENT DATE
280	AA	

APPLICATION NO. 09/695028	CONT/PRIOR	CLASS 216	SUBCLASS 2	ART UNIT 1746 1765	EXAMINER ALANKO
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APPLICANTS
Jason Benz

TITLE
Method for thin film laser reflectance correlation for substrate etch endpoint

PTO-2040
12/99

ISSUING CLASSIFICATION

ORIGINAL		CROSS REFERENCE(S)	
CLASS	SUBCLASS	CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)
INTERNATIONAL CLASSIFICATION			

Continued on Issue Slip Inside File Jacket

<input type="checkbox"/> TERMINAL DISCLAIMER <input type="checkbox"/> The term of this patent subsequent to (date) has been disclaimed. <input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S. Patent No. <input type="checkbox"/> The terminal months of this patent have been disclaimed	DRAWINGS Sheets Drwg. Figs. Drwg. Print Fig.			CLAIMS ALLOWED Total Claims Print Claim for O.G.	
	(Assistant Examiner) (Date)			NOTICE OF ALLOWANCE MAILED	
	(Primary Examiner) (Date)			ISSUE FEE Amount Due Date Paid	
	(Legal Instruments Examiner) (Date)			ISSUE BATCH NUMBER	

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